

Homework 8

1) $n_i = 2.5 \times 10^{13} \text{ cm}^{-3}$ $N_D = 5 \times 10^{13} \text{ cm}^{-3}$ $N_A = 2.5 \times 10^{13} \text{ cm}^{-3}$ $D_n = 100 \text{ cm}^2/\text{s}$ $D_p = 50 \text{ cm}^2/\text{s}$

a) $E_F - E_i = E_g = 0.67 \text{ eV}$

$V_T = 0.0259$

$n = \frac{\sqrt{(N_D - N_A) + (N_D - N_A)^2 + 4n_i^2}}{2} = 2.795 \times 10^{13} \text{ cm}^{-3}$

$\mu_n = \frac{D_n}{V_T} = 3861$

$\mu_p = \frac{D_p}{V_T} = 1930.5$

$q = 1.602 \times 10^{-19}$

$\sigma = q(n\mu_n + p\mu_p) = 0.024 \text{ cm/s}$

$p = \frac{n_i^2}{n} = 2.236 \times 10^{13} \text{ cm}^{-3}$

b) $\Delta\phi = \phi_M - \chi = 0.5 \text{ eV}$
 $4.5 \text{ eV} \quad 4.0 \text{ eV}$

Schottky barrier because $\phi_M > \chi$

2) $V_0 = 1.6$ $N_D = 10^{16}$ $N_A = 3 \times 10^{19}$ $E_1 = 12$ $E_2 = 13$

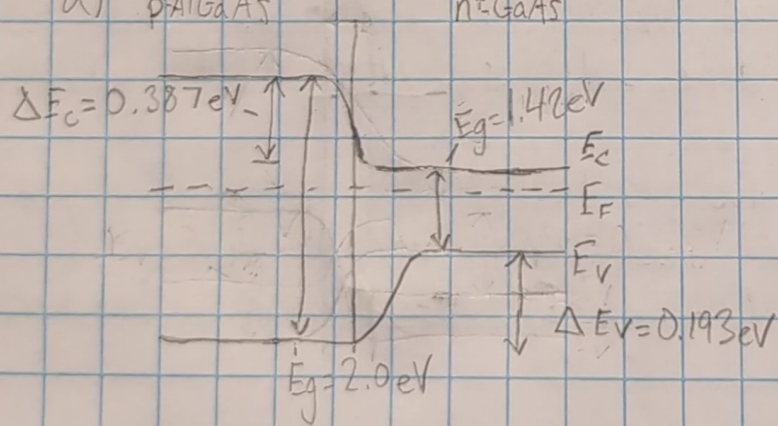
$V_0 = V_{01} + V_{02}$

$V_{01} = \frac{V_0}{(1 + \frac{E_1 N_A}{E_2 N_D})} = 0.578 \text{ mV}$

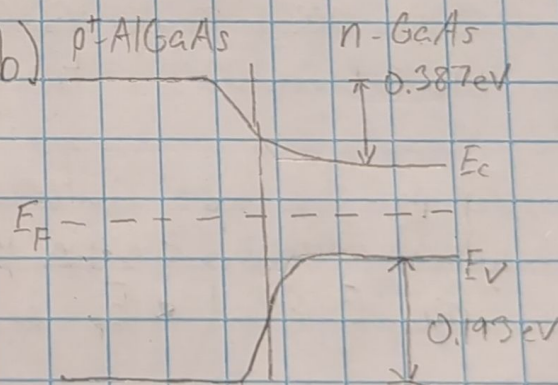
$V_{02} = V_0 - V_{01} = 1.59942 \text{ V}$

3) AlGaAs $E_g = 2.0 \text{ eV}$ GaAs $E_g = 1.42 \text{ eV}$ $\Delta E_g = 0.58 \text{ eV}$ $\Delta E_c = 0.387 \text{ eV}$ $\Delta E_v = 0.193 \text{ eV}$

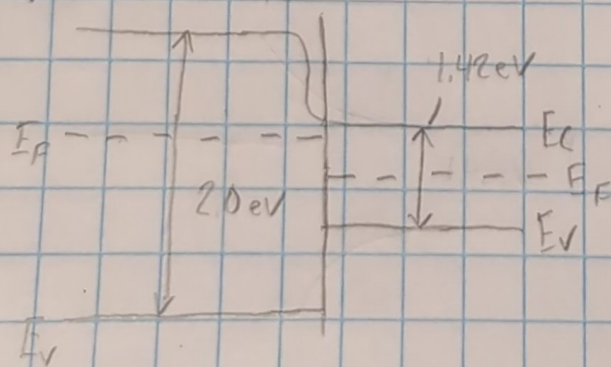
a) $p^+ \text{AlGaAs}$



b) $p^+ \text{AlGaAs}$



c) $n^+ \text{AlGaAs}$



4) $A = 4 \text{ cm}$ $I_{th} = 32 \text{ nA}$ $g_{op} = 10^{18} \text{ EHP/cm}^2\text{-s}$ $L_p = L_n = 2 \mu\text{m}$ $W = 1 \mu\text{m}$

$$I_{op} = q A g_{op} (L_p + L_n + W) = \boxed{32.04 \text{ nA}}$$

$$V_{oc} = \frac{kT}{q} \ln\left(\frac{I_{op}}{I_{th}} + 1\right) = \boxed{17.97 \text{ mV}}$$

5) $E_g = 2.5 \text{ eV}$

$$\lambda = \frac{1.24}{E_g} = \boxed{496 \text{ nm}}$$

$$E_{900} = \frac{hc}{\lambda(\mu\text{m})} = 1.38 \text{ eV} \rightarrow \boxed{\text{Can't detect } 900 \text{ nm photons}} \\ (1.38 < 2.5)$$

$$E_{100} = \frac{hc}{\lambda(\mu\text{m})} = 12.4 \text{ eV} \rightarrow \boxed{\text{Can detect } 100 \text{ nm photons}} \\ (12.4 > 2.5)$$

6) a) For carrier multiplication to occur, the diode needs a high electric field and/or special materials the p-i-n diode does not have. Gain is the ability for carrier multiplication to occur, so the diode has no gain.

b) To increase p-i-n diode sensitivity, the thickness of the intrinsic region needs to be increased. This additional width would cause an increase in carrier transit time, and thus decrease the device's speed.

c) To pick the best material we first need to compare the band gap, which determines the maximum wavelength a material can detect. Since $E_g \text{ of GaAs} < E_p$ and $E_g \text{ of CdS} > E_p$, GaAs would be the better material.

7) $T = 300K$ $N_a = 10^{16} \text{ cm}^{-3}$ $N_d = 10^{15} \text{ cm}^{-3}$ $D_n = 25 \text{ cm}^2/\text{s}$ $D_p = 10 \text{ cm}^2/\text{s}$
 $\tau_n = 10^{-6} \text{ s}$ $\tau_p = 5 \times 10^{-7} \text{ s}$ $A = 5 \text{ cm}^2$ $g_{op} = 5 \times 10^{21} \text{ cm}^{-3}\text{s}^{-1}$ $n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$

a) $L_n = \sqrt{D_n \tau_n} = 0.005 \text{ cm}$ $L_p = \sqrt{D_p \tau_p} = 0.0022 \text{ cm}$

$V_{bi} = \frac{kT}{q} \ln\left(\frac{N_a N_d}{n_i^2}\right) = 0.635 \text{ V}$

$\epsilon_s = \epsilon \cdot \epsilon_0 = 1.036 \times 10^{-12} \text{ F/cm}$

$W = \sqrt{\frac{2\epsilon_s V_{bi}}{q} (N_a^{-1} + N_d^{-1})} = 9.5 \times 10^{-5} \text{ cm} = 950 \text{ nm}$

$I_{sc} = q A g_{op} (L_n + L_p + W) = 4.185 \times 10^{-6} \text{ A} = \boxed{4.185 \mu\text{A}}$

b) $V_{oc} = \frac{kT}{q} \ln\left(\frac{L_n + L_p + W}{(L_p/\tau_p) D_n + (L_n/\tau_n) D_p \cdot g_{op} + 1}\right) = 0.01329 \text{ V} = \boxed{13.29 \text{ mV}}$

c) $\frac{V_{oc}}{V_{bi}} = \frac{0.01329}{0.635} = \boxed{0.020929}$